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Enhanced capacitance of nitrogen-doped hierarchically porous carbide-derived carbon in matched ionic liquids†

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Supercapacitors combine efficient electrical energy storage and performance stability based on fast electrosorption of electrolyte ions at charged interfaces. They are a central element of existing and emerging energy concepts. A better understanding of capacitance enhancement options is essential to exploit the full potential of supercapacitors. Here, we report a novel hierarchically structured N-doped carbon material and a significant capacitance enhancement for a specific ionic liquid. Our studies indicate that matching of the electrode material and the ionic liquid specifically leads to a constant normalized resistance of the electrode material (voltage window up to ± 1 V vs. carbon) and a significant enhancement of the specific capacitance. Such effects are not seen for standard organic electrolytes, non-matched ionic liquids, or non-N-doped carbons. A higher N-doping of the electrode material improves the symmetric full cell capacitance of the match and considerably increases its long-term stability at +3 V cell voltage. This novel observance of enhanced specific capacitance for N-doped carbons with matched ionic liquid may enable a new platform for developing supercapacitors with enhanced energy storage capacity.

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Introduction

Electrochemical capacitors, also known as supercapacitors or ultracapacitors, capitalize on the high efficiency and performance stability of fast electrosorption of electrolyte ions at the charged interface with nanoporous carbon.^{1,2} While derived from abundantly available biomass, commonly used high surface area carbons show only a moderate electrical conductivity, which presents a limitation to effective charge screening, leading to limited energy storage capacity.³ At a device level, this shortcoming is usually compensated by the admixing of conductive additives;⁴ yet, this approach is not an intrinsic solution for the inability to accommodate a high amount of electric charge within the carbon nanopores.

The beneficial impact of N-doping on the electrical conductivity and, more generally, the electrochemical performance of supercapacitors has first been investigated by Lota *et al.* in polymer-derived carbons.⁵ By now, a series of carbon materials with N-doping has been explored, including carbon

nanotubes,^{6,7} mesoporous carbon spheres,⁸ biomass-derived porous carbon,⁹ metal-organic frameworks,¹⁰ and graphene-like carbon.¹¹ Nitrogen can be introduced into carbon, generally, top-down or bottom-up. The latter involves the synthesis of a carbon network and subsequent N-doping *via* annealing, for example in ammonia.¹² Alternatively, N-doping can be accomplished very effectively by using nitrogen-containing precursor materials, including bio-materials like prawn shells or yogurt^{9,13} or ionic liquids.¹⁴ Depending on the synthesis procedure and the maximum synthesis temperature, the maximum amount of N-doping in carbon may reach around 21 mass%.¹⁵ In general, we find lower nitrogen content when employing higher synthesis temperatures¹⁵ and a significant improvement of the electrochemical performance has been reported already for rather low amounts of nitrogen, such as 1–2 mass%.⁵

Besides improving the electrical conductivity and increasing the charge screening ability of carbon,⁷ N-sites at the carbon surface may facilitate charge transfer across the electrode/electrolyte interface. Such redox-sites may contribute significantly to the energy storage mechanism by enabling access to reversible faradaic reactions and possibly pseudocapacitance;^{11,16} yet, this is often accomplished at the cost of sacrificing power handling and longevity to some degree.²

Considering the high ion mobility and the possible benefit of redox-related charge storage, most of the investigations of nitrogen-doped carbons have been carried out in aqueous electrolytes, foremost H₂SO₄ (ref. 5, 6 and 17) and KOH.⁵ In such

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systems, an enhancement of the electrochemical performance is accomplished by the introduction of fast surface redox-reactions of quaternary nitrogen and other N-groups with the protic electrolyte. Only a small number of studies, so far, have been carried out on organic electrolytes,⁵ including ionic liquids.¹⁸ The latter are a highly promising group of electrolytes that are able to push the voltage limit of supercapacitors to at least 3.5 V even for long-term operation,¹⁹ while benefitting from a non-volatile and temperature-stable nature at the cost of low ion mobility.²⁰ Since the stored amount of energy scales with the square of the cell voltage, ionic liquids are attractive candidates for high-energy supercapacitor devices.²¹ While the results for many of the N-doped carbons are promising, one aspect has somewhat been overlooked: the intricate correlation between ions and the carbon surface. Matching the ionic liquid to an optimized voltage window has recently been demonstrated for pure carbon materials,²² but it is still unclear what selection strategy should be applied for matching an ionic liquid to nitrogen-doped carbon.

Herein, we report a novel hierarchically porous N-doped carbon material obtained from meso-structured polymer derived silicon carbonitride and the electrochemical performances in different ionic liquids. We observe a significantly improved capacitance for one specific ionic liquid and an increased N-doping improves the symmetric full cell capacitance as well as the long-time stability of such cells at high voltage.

Results and discussion

Preparation of the hierarchically porous N-doped carbon material

Since the template free synthesis of polymer-derived silicon carbon nitride (SiCN) materials leads neither to micropores nor to mesopores,²³ we decided to synthesize a polystyrene-poly-silazane nanocomposite regarding meso-structuring.²⁴ Therefore, positively charged polystyrene (PS) spheres with a diameter of about 50 nm (PS₅₀) were synthesized as structuring templates *via* emulsion polymerization (Fig. 1; see also ESI, Fig. S1†). The particles were mixed in toluene with commercially available polysilazane HTT-1800. Divinylbenzene (DVB) was used as a cross-linker stabilizing the particles in toluene. Thus, an enhanced yield of residual carbon can be obtained. Evaporation of the solvent gave rise to the nano-composite green body. The green body was pyrolyzed at 900 °C in order to remove the PS₅₀ template and led to the thermally stable meso-structured SiCN material PS₅₀SiCN₉₀₀. (Fig. 1; see also ESI, Fig. S2†). Chlorine treatment, commonly used for the synthesis of carbide-derived carbons (CDC),²⁵ was employed at 800 °C (PS₅₀SiCN₉₀₀Cl₂-800°C) and 1000 °C (PS₅₀SiCN₉₀₀Cl₂-1000°C) to volatilize residual silicon and partially mobilize silicon nitride.²⁶

Material characterization

Transmission electron microscopy (TEM) images of PS₅₀-SiCN₉₀₀Cl₂-800°C before and after chlorine treatment are shown in Fig. 1. For scanning electron microscopy (SEM) and TEM images of all materials, see ESI, Fig. S1–S3.† As common for

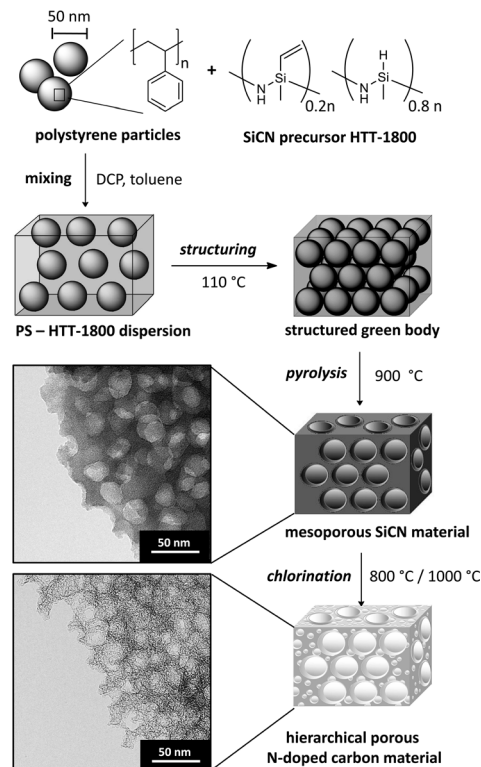


Fig. 1 Schematic process of the synthesis of the N-doped hierarchically porous carbon materials and transmission electron microscopy (TEM) images of PS₅₀SiCN₉₀₀ (left, top) PS₅₀SiCN₉₀₀Cl₂-800°C (left, bottom) following a three step procedure. (1) Mixing 50 nm polystyrene (PS₅₀) particle template, the commercially available SiCN precursor HTT-1800, and dicumylperoxide (DCP, crosslinker) in toluene as well as structuring by removal of the solvent. (2) Pyrolysis at 900 °C obtaining the mesoporous SiCN material PS₅₀SiCN₉₀₀. (3) Chlorination at 800 °C or 1000 °C leading to the hierarchically porous N-doped carbon material PS₅₀SiCN₉₀₀Cl₂-800°C and PS₅₀SiCN₉₀₀Cl₂-1000°C, respectively.

CDC,²⁷ our materials remained conformal after chlorine gas treatment, preserving the structure of the mesoporous SiCN material and adding additional pores so that a very high pore volume (up to 1.67 cm³ g⁻¹) was reached.

The SiCN material PS₅₀SiCN exhibits a characteristic nitrogen sorption isotherm typical for a purely mesoporous material (Fig. 2A).²⁸ The nitrogen gas sorption isotherms of the material after chlorine gas treatment were a combination of the IUPAC Type I and Type IV isotherm with a pronounced Type H2 hysteresis in reflectance of the mixed micro- and mesoporous pore structure (Fig. 2B).²⁸ Compared to the mesoporous SiCN material (107 m² g⁻¹), the BET surface area strongly increases as a result of chlorine etching at 800 °C to 1745 m² g⁻¹ and at 1000 °C to 1817 m² g⁻¹ (Table 1). PS₅₀SiCN₉₀₀Cl₂-800°C is dominated by mesopores, 71% of the pore volume (Table 1). In contrast, PS₅₀SiCN₉₀₀Cl₂-1000°C shows approximately a one-to-one distribution of micro- and mesopores at a lower total pore volume (1.19 cm³ g⁻¹ instead of 1.67 cm³ g⁻¹). The smaller pore volume may result from an enhanced carbon sintering and pore coalescing at 1000 °C.²⁹ The hierarchical pore size distributions observed for both N-doped carbon materials facilitates access of



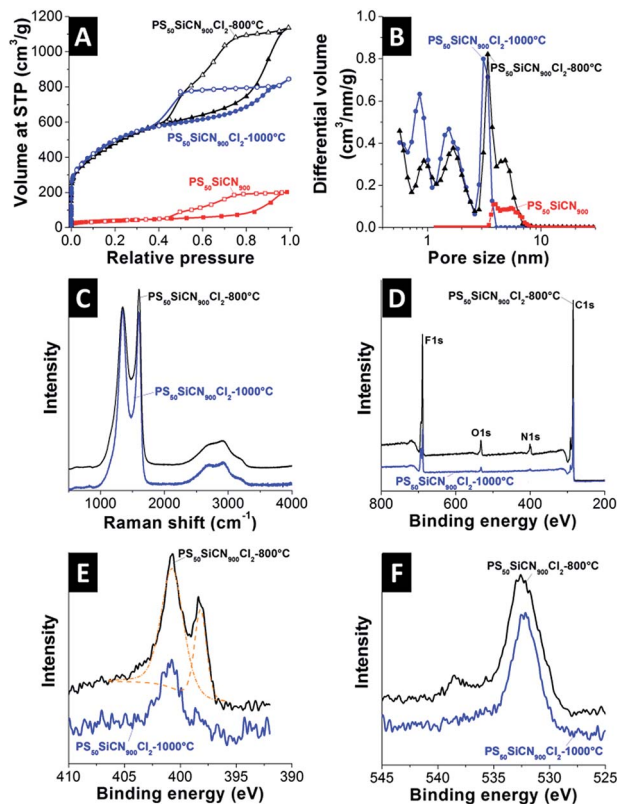


Fig. 2 Characterization of the hierarchically porous nitrogen-doped carbon materials (A) nitrogen sorption isotherms and (B) calculated pore size distribution of the ceramic template and the chlorinated materials. (C) Raman spectra of the samples PS₅₀SiCN₉₀₀-800°C and PS₅₀SiCN₉₀₀-1000°C, (D) XPS survey spectra of the samples PS₅₀SiCN₉₀₀-800°C and PS₅₀SiCN₉₀₀-1000°C, (E) N 1s high resolution spectrum of PS₅₀SiCN₉₀₀-800°C and PS₅₀SiCN₉₀₀-1000°C, and (F) O 1s high resolution spectrum of PS₅₀SiCN₉₀₀-800°C and PS₅₀SiCN₉₀₀-1000°C.

ionic liquid ions to the pores (Table 1). The diameter of the largest mesopores is significantly smaller than 50 nm (diameter of the used PS templates) due to incomplete cracking of the PS template during pyrolysis (Fig. 2B).

The materials after chlorine gas treatment showed Raman spectra with pronounced D- and G-peaks around 1350 cm⁻¹ and 1590 cm⁻¹, respectively, as typical for incompletely graphitized carbons (Fig. 2C).³⁰ With increased chlorination temperature, the degree of carbon ordering increases indicated by the small decrease of the integral I_D/I_G signal ratio from 2.3 to 2.1.

The insertion of nitrogen into the carbon network was confirmed by X-ray photoelectron emission spectroscopy (XPS) (Fig. 2D–F and Table 1) and elemental analysis (EA) (Table 1). The chlorination temperature had a strong effect on N-doping. The decrease of the temperature during the chlorination process caused a lower nitrogen removal and a higher amount of nitrogen in the final carbon material (Table 1).¹⁵

Electrochemical measurements

Next, we investigated the electrochemical behavior of the N-doped carbon materials. As seen from the cyclic

Table 1 Pore characteristics derived from nitrogen gas sorption at liquid nitrogen temperature and nitrogen content calculated from ^aelemental analysis (EA) and ^bX-ray photoelectron spectra (XPS) for the samples after chlorine gas treatment

	PS ₅₀ SiCN ₉₀₀	PS ₅₀ SiCN ₉₀₀ -Cl ₂ -800°C	PS ₅₀ SiCN ₉₀₀ -Cl ₂ -1000°C
BET SSA (m ² g ⁻¹)	106	1745	1817
DFT SSA (m ² g ⁻¹)	117	1536	1516
V _{total} (cm ³ g ⁻¹)	0.27	1.67	1.19
V _{micropores} (cm ³ g ⁻¹)	0	0.47	0.59
V _{mesopores} (cm ³ g ⁻¹)	0.27	1.19	0.60
Pore size average (nm)	4.4	3.3	2.0
N (mass%) ^a	Not measured	5.5	1.6
N (mass%) ^b	Not measured	4.6	1.1

voltammograms (CV) of PS₅₀SiCN₉₀₀Cl₂-800°C (Fig. 3A) and PS₅₀SiCN₉₀₀Cl₂-1000°C (Fig. 3B), stable electrochemical performance is obtained in the studied voltage window (up to ±1 V vs. carbon, equivalent to 2 V cell voltage).³¹ As shown for galvanostatic charge/discharge data (ESI, Fig. S4A and S4B†), a maximum specific capacitance of 151 F g⁻¹ at -1 V vs. carbon is seen for PS₅₀SiCN₉₀₀Cl₂-800°C in combination with 1-ethyl-3-methylimidazolium tetrafluoroborate (EMIM-BF₄), reflecting the behavior of the CV curves. In contrast, 1 M tetraethylammonium tetrafluoroborate (TEA-BF₄) in acetonitrile (ACN) results in 121 F g⁻¹ and 122 F g⁻¹ for neat 1-ethyl-3-methylimidazolium bis(trifluoromethyl-sulfonyl)imide (EMIM-TFSI). The same behavior is seen for PS₅₀SiCN₉₀₀Cl₂-1000°C, with a maximum capacitance of 149 F g⁻¹ for EMIM-BF₄ and only 126 F g⁻¹ for 1 M TEA-BF₄ in either propylene carbonate (PC) or ACN. The only difference between the latter two solvents, as seen from the CV in Fig. 3B, is the lower ion mobility during charging and discharging for PC. Neat 1-butyl-3-methylimidazolium tetrafluoroborate (BMIM-BF₄) also yields a lower capacitance, namely 134 F g⁻¹. The capacitance values of different N-doped carbon electrodes with aqueous and non-aqueous electrolytes found in the literature are compared in Table 2.

To find a possible explanation for the difference in capacitance, the ohmic resistance of the N-doped carbon materials was measured in the charged state of the electrodes.^{37,38} This way, it was possible to address the change in electronic properties uninfluenced by the electrolyte. As seen in Fig. 3C, an expected behavior is recorded for the standard electrolyte based on ACN, namely a characteristic bell-shaped curve with a decrease in normalized resistance at increased potential. As shown in Fig. 3B and C the PC-based electrolyte shows comparable capacitance values compared to the ACN based electrolyte, indicating that the resistance behavior is also very similar (*cf.* ref. 38). For the EMIM-BF₄ system, no decrease in normalized resistance is measured (Fig. 3C), indicating interactions of the electrolyte with the electrode material, considering that only the electrolyte was changed. This is additionally confirmed by measuring the *in situ* resistivity of EMIM-BF₄ in a standard activated carbon (YP80F from Kuraray, Fig. S4C†). Here, the typical voltage-dependency of the normalized



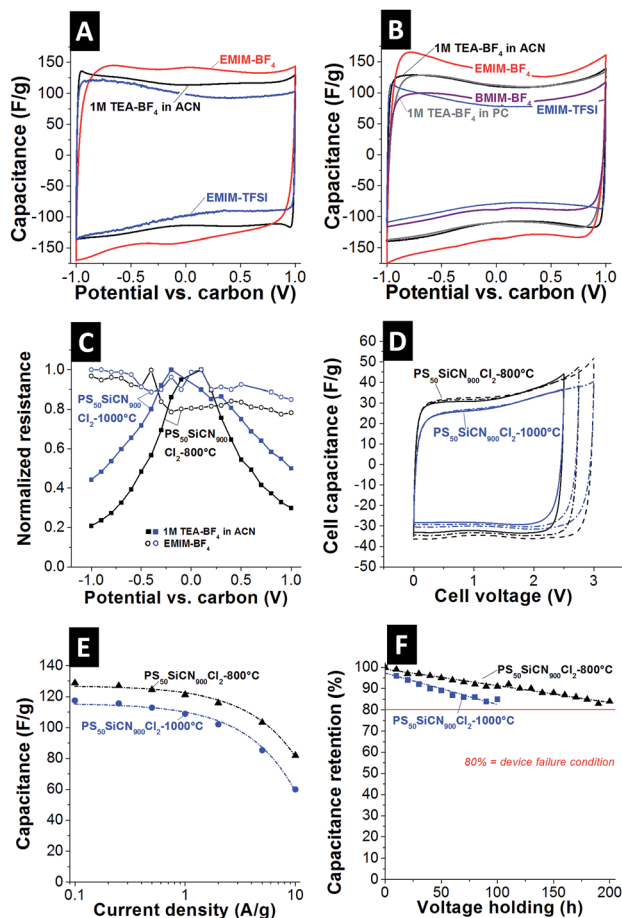


Fig. 3 Cyclic voltammograms of $\text{PS}_{50}\text{SiCN}_{900}\text{Cl}_2\text{-}800^\circ\text{C}$ (A) and $\text{PS}_{50}\text{SiCN}_{900}\text{Cl}_2\text{-}1000^\circ\text{C}$ (B) in the range of ± 1 V vs. carbon, scan rate: 10 mV s^{-1} . (C) *In situ* resistivity measurements for $\text{PS}_{50}\text{SiCN}_{900}\text{Cl}_2\text{-}800^\circ\text{C}$ and $\text{PS}_{50}\text{SiCN}_{900}\text{Cl}_2\text{-}1000^\circ\text{C}$ with 1 M TEA- BF_4 and EMIM- BF_4 as electrolytes. (D) Full cell cyclic voltammograms of $\text{PS}_{50}\text{SiCN}_{900}\text{Cl}_2\text{-}800^\circ\text{C}$ and $\text{PS}_{50}\text{SiCN}_{900}\text{Cl}_2\text{-}1000^\circ\text{C}$ with EMIM- BF_4 as the electrolyte, scan rate: 10 mV s^{-1} . (E) Rate handling behavior of $\text{PS}_{50}\text{SiCN}_{900}\text{Cl}_2\text{-}800^\circ\text{C}$ and $\text{PS}_{50}\text{SiCN}_{900}\text{Cl}_2\text{-}1000^\circ\text{C}$. (F) Long term stability test at 3 V cell voltage of $\text{PS}_{50}\text{SiCN}_{900}\text{Cl}_2\text{-}800^\circ\text{C}$ and $\text{PS}_{50}\text{SiCN}_{900}\text{Cl}_2\text{-}1000^\circ\text{C}$ in EMIM- BF_4 .

Table 2 Comparison of the capacitance values of different N-doped carbon supercapacitor electrodes with aqueous and non-aqueous electrolytes in the literature

Publication	Electrolyte	Capacitance (F g^{-1})
5	1 M H_2SO_4	95–201
5	1 M TEA- BF_4 /ACN	52–114
17	1 M H_2SO_4	Up to 264
32	1 M H_2SO_4	95–182
33	1 M H_2SO_4	205
34	1 M LiPF ₆ in EC/DMC	159
35	6 M KOH	202
36	6 M KOH	Up to 420

resistance is seen again for EMIM- BF_4 . Thus, the unique behavior of a virtually constant profile of the electrical conductivity is only achieved by a suitable match between the

electrode material (*i.e.*, N-doped carbon) and the electrolyte. Additionally, the pore hierarchy supports the ion transport. In principle, larger pores (like mesopores) facilitate ion mobility in micrometer-sized particles, while, at the same time, a large amount of mesopores is essential to enable a high specific capacitance (*i.e.*, high ion storage ability).³⁹ Noticeably, the CV shape does not indicate the occurrence of any further processes, such as ion depletion or surface saturation.^{1b} This is further supported when comparing the cyclic voltammograms of SiC-CDC- 800°C and $\text{PS}_{50}\text{SiCN}_{900}\text{Cl}_2\text{-}800^\circ\text{C}$ (Fig. S4D†). The performance of the non N-doped material is clearly inferior to that of $\text{PS}_{50}\text{SiCN}_{900}\text{Cl}_2\text{-}800^\circ\text{C}$ in terms of capacitance and rate capability.

To check whether the performance of a single electrode as presented before can be translated to a full cell, symmetric full cells were constructed (Fig. 3D). First, the potential window was opened successively up to 3 V cell voltage with a scan rate of 10 mV s^{-1} . The cell capacitance of $\text{PS}_{50}\text{SiCN}_{900}\text{Cl}_2\text{-}800^\circ\text{C}$ (*ca.* 34 F g^{-1}) is higher than that of $\text{PS}_{50}\text{SiCN}_{900}\text{Cl}_2\text{-}1000^\circ\text{C}$ (*ca.* 30 F g^{-1}). Note that the values for the cell capacitance can be transformed to the specific capacitance (for one electrode) by multiplying by a factor of 4. The data from cyclic voltammetry agree well with galvanostatic charge/discharge measurements. At a low current density of 0.1 A g^{-1} , the specific capacitance of $\text{PS}_{50}\text{SiCN}_{900}\text{Cl}_2\text{-}800^\circ\text{C}$ (129 F g^{-1}) is higher than that of $\text{PS}_{50}\text{SiCN}_{900}\text{Cl}_2\text{-}1000^\circ\text{C}$ (118 F g^{-1}). Up to 2 A g^{-1} , both materials display a high rate capability before the capacitance fades at higher current densities.

Finally, the long-term stability at 3 V cell voltage was tested by voltage floating.⁴⁰ Both cells are characterized by a decay in capacitance over time (Fig. 3F); however, $\text{PS}_{50}\text{SiCN}_{900}\text{Cl}_2\text{-}800^\circ\text{C}$ lasted approximately twice as long as $\text{PS}_{50}\text{SiCN}_{900}\text{Cl}_2\text{-}1000^\circ\text{C}$ at an elevated voltage of 3 V. A drop of 20% in capacitance, the common device failure definition in industry,⁴ was not seen within 200 h for $\text{PS}_{50}\text{SiCN}_{900}\text{Cl}_2\text{-}1000^\circ\text{C}$ in EMIM- BF_4 . The cycling stability up to 3 V cell voltage (ESI, Fig. S5†) indicates that after a drop in capacitance at the beginning the cell approaches a stable performance after 1000 cycles.

Conclusions

In summary, we synthesized a hierarchically porous N-doped carbon material with different distributions of meso- and micropores as well as varied N-doping. Both N-doped materials show significant capacitance enhancement for the ionic liquid EMIM- BF_4 in comparison to 1 M TEA- BF_4 in ACN or EMIM-TFSI. In addition, N-doped carbon in combination with EMIM- BF_4 shows a nearly constant normalized resistance from -1 V to $+1$ V. Distinct differences were observed for both electrode materials in symmetric full cells. The nitrogen-richer carbon material shows a higher cell capacitance and twice as high long-term stability at 3 V cell voltage.

For the moment, the mechanisms causing the enhanced specific capacitance for the matched ionic liquid EMIM- BF_4 compared to other electrolytes (such as EMIM-TFSI or when using organic solvents) remain unclear. Yet, the electrochemical data show that processes like ion sieving or ion saturation cannot cause the phenomenon. Instead, electrical conductivity



shows an anomalous enhancement in electrical conductivity of the N-doped carbon electrode material only when using EMIM-BF₄. Noticeably, this is not seen for conventional porous carbon (*i.e.*, without N-doping). The unique solid-state response of N-doped carbon to a specific ionic liquid is an intriguing effect to be unraveled in future work.

Experimental section

Materials

Synthesis was performed in a dry argon atmosphere using standard Schlenk techniques. Halogenated solvents were dried over P₂O₅ and non-halogenated solvents over sodium benzo-phenone ketyl. All chemicals were purchased from commercial sources with a purity over 95% and used without further purification unless described detailed below.

Synthesis of the PS₅₀ template

The cross-linked polystyrene particles with an average diameter of 50 nm were synthesized by emulsion polymerization. Therefore, a three neck round bottom flask with a KPG stirrer and a reflux condenser was used. Divinylbenzene (DVB, technical grade, 55%, Sigma Aldrich) and styrene (>99% purity, Sigma Aldrich) were purified by destabilization (alumina B column, ICN Biomedicals GmbH). A dispersion of 4.10 g styrene (39.39 mmol) and 0.40 g DVB (3.07 mmol) was stirred in 90 mL ultrapure water. The dispersion was degassed for 30 min. After that, a solution of 0.25 g (1-hexadecyl)trimethyl-ammonium-bromide (0.69 mmol) (CTAB, 98% purity, abcr GmbH) in 5 mL ultrapure water was added under stirring (200 rpm) at 80 °C. After 0.5 h, 0.01 g 2,2'-azobis(2-methylpropionamide)di-hydrochloride (0.04 mmol) (97% purity, Sigma Aldrich) was added initiating the polymerization. Polystyrene particles were dialyzed for purification and freeze dried.

Synthesis of PS₅₀SiCN₉₀₀ material

For several hours the polystyrene template PS₅₀ was evacuated removing residual water. After that, a solution of 0.50 g of KiON HTT1800 (7.77 mmol) (Clariant Advanced Materials GmbH) and 0.05 g dicumylperoxide (1.85 mmol) (97% purity, Sigma Aldrich) in 40 mL toluene was added under stirring. The dispersion was heated to 110 °C for 24 h without stirring. After removal of the solvent the *in situ* structured green body was treated at 110 °C for 24 h finalizing the cross-linking. The PS₅₀SiCN₉₀₀ green body was pyrolyzed under a nitrogen atmosphere according to the following procedure: to 300 °C at 1 °C min⁻¹ (held for 3 h), to 400 °C at 1 °C min⁻¹ (held for 3 h), to 500 °C at 0.5 °C min⁻¹ (held for 3 h), to 600 °C at 1 °C min⁻¹ (held for 4 h), to 700 °C at 0.5 °C min⁻¹ (no holding time), and finally to 900 °C at 1 °C min⁻¹ (held for 0.5 h). A Gero furnace was used for this task.

Synthesis of N-doped carbon

For the chlorine treatment around 3 g of PS₅₀SiCN₉₀₀ powder was put into a graphite crucible and placed in a quartz tube furnace (Gero F-A 40-200). The tube was flushed with a constant argon flow of 20 sccm for at least 8 h. During heating, chlorine

and hydrogen treatment, the argon background flow was set to 100 sccm. The heating rate was 15 °C min⁻¹ and the oven was held for 6 h at each chlorination temperature (600 °C, 800 °C, and 1000 °C). During the dwell time, the chlorine gas flow was set to 10 sccm. After cooling to 600 °C with 15 °C min⁻¹, the chlorine gas flow was stopped and 10 sccm hydrogen gas was applied for 3 h to remove residual chlorine. At the end, the furnace was cooled down to room temperature with a constant argon flow of 20 sccm. The same procedure was followed for the synthesis of SiC-CDC-800 °C (Precursor: Nano SiC, Plasmachem; average particle size *ca.* 20–30 nm).

Materials characterization

Elemental analyses were carried out on a Vario elemental EL III. Thermal gravimetric analysis (TGA) was carried out under a nitrogen atmosphere using a Thermowaage L81 (Linseis, Germany). With a heating rate of 5 °C min⁻¹ the sample was heated to 900 °C. Photon correlation spectroscopy (PCS) was performed using an ALV DLS/SLA-SP 5022F laser goniometer system. The power source was a Ne/Ar ion laser ($\lambda = 632.8$ nm at 260 mW). By using an ALV-5000/E multiple tau digital correlator the correlation function was generated. The decalin bath temperature was 20 °C, regulated by using a computer-operated thermostat. 90° fixed angle measurements were carried out. Data were analyzed by the CONTIN analysis. On a Zeiss field emission SEM LEO 1530 GEMINI scanning electron microscopy (SEM) was performed. The acceleration voltage was up to 5 kV and the materials were sputter-coated with a 1.3 nm platinum layer. Fourier transform infrared (FTIR) measurements were carried out using a Perkin-Elmer FTIR Spectrum 100 (from 4400 to 650 cm⁻¹). Raman spectra of the raw materials were recorded with a Renishaw inVia Raman system using an Nd-YAG laser (532 nm) with 0.2 mW power at the sample surface. The peak analysis and peak fitting were performed assuming one Lorentzian peak for both the D-mode and G-mode. Nitrogen gas sorption measurements (–196 °C) of the electrodes (*i.e.*, carbon + binder) were performed with an Autosorb iQ system (Quantachrome, USA). The materials were outgassed at 150 °C for 10 h in a vacuum. The specific surface area was calculated using the ASiQwin-software using the Brunauer–Emmett–Teller (BET) equation in the linear relative pressure range of 0.01–0.2. The SSA and pore size distribution (PSD) were also calculated *via* quenched-solid density functional theory (QSDFT) with a hybrid model for slit and cylindrical pores and pore size between 0.56 and 37.5 nm. Samples for transmission electron microscopy (TEM) were dispersed and sonicated in chloroform and placed on a copper grid (CF200-Cu-grid, Electron Microscopy Sciences, Hatfield, PA, USA). The TEM images were taken with a Varian LEO 9220 (120 kV, Carl Zeiss) and a JEOL 2100F system at 200 kV. X-ray photoelectron spectroscopy (XPS) measurements were performed using a VG ESCALAB 220iXL spectrometer (Thermo Fisher Scientific) equipped with an Al-K α mono-source (power: 150 W; spot diameter: 500 μ m) and a magnetic lens system. The spectra were recorded in constant analyzer energy mode at a pass energy of 20 eV. The XPS was calibrated using the Ag 3d_{5/2}, the Cu 2p_{3/2}, and the Au 4f_{7/2} lines as reference signals. The full-



width half maximum (FWHM) of the Ag 3d_{5/2} line was measured to be 0.62 eV at a pass energy of 20 eV. The data were evaluated using the Avantage software provided by Thermo Fisher Scientific. The background subtraction was performed according to Shirley⁴¹ and atomic sensitivity factors were used according to Scofield.⁴²

Electrode preparation

Electrodes were prepared using sample powder dispersed in ethanol. After homogenization in a mortar, 5–10 mass% of dissolved polytetrafluoroethylene (PTFE, 60 mass% solution in water from Sigma Aldrich) were added as binders. While kneading, the slurry became more viscous and the resulting material was rolled with a rolling machine (MTI HR01, MIT Corp.) to a 200 ± 20 μm thick free standing electrode and dried at 120 °C at 2 kPa for 24 h. We employed a custom-built polyether ether ketone (PEEK) cell with spring loaded titanium pistons as a three electrode system described elsewhere.⁴⁰ The cells employed electrodes with 12 mm diameter, a glass-fiber separator (GF/A (for full cells) or GF/D (for half cells)) from (Whatman, USA), and carbon-coated aluminum foil current collectors (type Zflo 2653, Coveris Advanced Coatings). PTFE-bound YP-50F was used as the reference electrode.⁴³ The assembled cells were dried at 120 °C for 12 h at 2 kPa in an inert gas glovebox (MBraun Labmaster 130, O₂ and H₂O < 1 ppm) and, after cooling to room temperature, vacuum-filled with 1 M tetraethylammonium tetrafluoroborate (TEA-BF₄) of electrochemical grade (*i.e.*, water content < 20 ppm), acetonitrile (ACN) or propylene carbonate (PC) purchased from BASF. The used ionic liquids 1-ethyl-3-methylimidazolium bis(trifluoromethylsulfonyl)-imide (EMIM-TFSI; >99%, Sigma Aldrich) and 1-ethyl-3-methylimidazolium tetrafluoroborate (EMIM-BF₄; >99%, IoLiTec Ionic Liquids Technologies) were degassed using a Schlenk tube in a Si-oil bath heated to 100 °C and a vacuum of 1 Pa was applied for at least 6 h to remove residual gas and water.

Electrochemical testing: the electrochemical measurements were carried out using a potentiostat/galvanostat VSP300 from Bio-Logic, with cyclic voltammetry (CV), galvanostatic cycling with potential limitation (GCPL), and electrical impedance spectroscopy (EIS). CVs were recorded in half cell mode at 1, 10, 100 and 1000 mV s⁻¹ in the potential range of 0 to 1 V vs. carbon with activated carbon (YP50, Kuraray chemicals) as the reference electrode.^{43,44} GCPL in half cell mode was performed to access the maximum available capacitance values from discharge in the range of ±1 V. The cell was charged for 10 min up to the desired potential and then discharged to 0 V. The capacitance was determined in 100 mV steps. Full cells were prepared for further testing in CV and GCPL mode. The CVs were recorded up to 3 V with 10 mV s⁻¹. In GCPL mode, the current density was increased in several steps from 0.1 A g⁻¹ to 10 A g⁻¹ with 10 s resting period between charging/discharging to access information on the IR-drop. The voltage holding experiments were performed at 3 V cell voltage with 10 h holding periods followed by 3 galvanostatic charge/discharge cycles to determine the capacitance. This was repeated for at

least 10 times. The galvanostatic cycling experiments (see ESI, Fig. S5†) were performed at 1 A g⁻¹.⁴⁰ The *in situ* resistance measurements were conducted with a system described in ref. 37. The working electrode was galvanostatically charged to the favored potential and after cell charging, the working electrode cable was removed and a multimeter was used for measuring the resistance between the other two gold contacts (accuracy: ±1.5%). This two-contact-point electrical conductivity probe for *in situ* measurements at various states of electrode charge was shown to yield data consistent with a four-point probe setup by Kastening *et al.* shown in ref. 45.

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